

AMENDMENTS TO THE SPECIFICATION:

Page 3, replace the paragraph, beginning on line 16, with the following amended paragraph:

--According to the method of manufacturing antistatic films applied to X-Ray films, sample X-Ray films are made different stepwise in electrostatic charges by adding one or more surface active agents selected from a group of fluorochemical surface active agents and polyoxyethylene surface active agents to surface protection layers of the sample X-Ray films. [[9.]] Further, the [[ample]] sample X-Ray films are made different stepwise in surface resistivity by adding fine particles of one or more metal oxides selected from a group of ZnO, TiO₂, SnO₂, TaI₂O₃, In₂O₃, SiO₂, MgO, BaO and MoO to surface protection layers of the sample X-Ray films.--